This article was downloaded by: On: 24 January 2011 Access details: Access Details: Free Access Publisher Taylor & Francis Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-41 Mortimer Street, London W1T 3JH, UK



#### Journal of Macromolecular Science, Part A

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713597274

## Photocrosslinkable Vinyl Esters with $\alpha$ , $\beta$ -Unsaturated Ketone Groups in the Backbone

M. S. Mirza<sup>a</sup>; N. G. Navale<sup>a</sup>; D. S. Sadafule<sup>a</sup>; C. G. Kumbhar<sup>a</sup>; S. P. Panda<sup>a</sup> <sup>a</sup> Faculty of Explosives, Applied Chemistry Institute of Armament Technology Girinagar, Pune, India

To cite this Article Mirza, M. S. , Navale, N. G. , Sadafule, D. S. , Kumbhar, C. G. and Panda, S. P.(1990) 'Photocrosslinkable Vinyl Esters with  $\alpha$ ,  $\beta$ -Unsaturated Ketone Groups in the Backbone', Journal of Macromolecular Science, Part A, 27: 1, 1-22

To link to this Article: DOI: 10.1080/00222339009351483 URL: http://dx.doi.org/10.1080/00222339009351483

### PLEASE SCROLL DOWN FOR ARTICLE

Full terms and conditions of use: http://www.informaworld.com/terms-and-conditions-of-access.pdf

This article may be used for research, teaching and private study purposes. Any substantial or systematic reproduction, re-distribution, re-selling, loan or sub-licensing, systematic supply or distribution in any form to anyone is expressly forbidden.

The publisher does not give any warranty express or implied or make any representation that the contents will be complete or accurate or up to date. The accuracy of any instructions, formulae and drug doses should be independently verified with primary sources. The publisher shall not be liable for any loss, actions, claims, proceedings, demand or costs or damages whatsoever or howsoever caused arising directly or indirectly in connection with or arising out of the use of this material.

# PHOTOCROSSLINKABLE VINYL ESTERS WITH $\alpha,\beta$ -UNSATURATED KETONE GROUPS IN THE BACKBONE

M. S. MIRZA, N. G. NAVALE, D. S. SADAFULE, C. G. KUMBHAR, and S. P. PANDA

Faculty of Explosives and Applied Chemistry Institute of Armament Technology Girinagar, Pune 411025, India

#### ABSTRACT

Five vinyl esters with  $\alpha,\beta$ -unsaturated ketone groups in their backbones have been synthesized from the corresponding diepoxides and acrylic acid with benzyltrimethylammonium methoxide as catalyst. The resins have been characterized by UV, IR, and mass spectral analysis, and their photoreactions have been studied under intense UV irradiation. The vinyl esters have been found to crosslink with UV light much faster than the parent diepoxides. On the other hand, a vinyl ester obtained from diglycidyl ether of Bisphenol A (VE) without the  $\alpha,\beta$ -unsaturated ketonic group undergoes very slow photocrosslinking. Interestingly, the vinyl esters also cure chemically with styrene, methyl ethyl ketone (MEK) peroxide, and cobalt naphthenate within 30 min at 98°C, with the exception that VE does not crosslink under similar conditions. This leads to the conclusion that synergy in photo- and chemical curing can be obtained by symmetrically coupling the vinyl end groups of vinyl esters with the  $\alpha_{\beta}$ unsaturated ketonic moiety.

#### INTRODUCTION

In one of our recent publications [1], the synthesis, characterization, and photoreactions of a vinyl ester obtained from the diglycidyl ether of 4,4'-dihydroxychalcone by reaction with acrylic acid with N,N-dimethylaniline as catalyst was reported. It was found that the vinyl ester crosslinked faster than the parent diglycidyl ether, while remaining chemically curable with styrene, MEK peroxide, and cobalt naphthenate. Such resins are known to be tough, chemically resistant, and bond well to Kevlar fiber [2]. Thus they promise to be good matrix material for Kevlar fiber composites, intended for use as body armor against fragmentation attack. We therefore thought it worthwhile to extend our previous work to the synthesis of a number of vinyl esters and to study their photoreactions under UV irradiation. In this paper, five such resins are synthesized and characterized, and their photocrosslinking is investigated.

#### **EXPERIMENTAL**

#### Synthesis of Dihydroxy $\alpha,\beta$ -Unsaturated Ketones

4,4'-Dihydroxybenzylideneacetophenone (chalcone) was prepared after Sheik [3] and had a melting point of 205°C. 4,4'-Dihydroxydibenzalacetone, 2,5-bis(4-hydroxybenzylidene)cyclopentanone, 2,5-bis(4-hydroxy-3-methoxybenzylidene)cyclopentanone, and 2,6-bis(4-hydroxybenzylidene)cyclohexanone were synthesized after Borden [4] and had melting points of 235, 307 (319-321 in Ref. 4), 207 (214-215 in Ref. 4), and 280°C (282-288°C in Ref. 4), respectively. The purity of the dibenzylidene compounds was tested by mass spectral analysis.

#### Synthesis of Diglycidyl Ethers

Diglycidyl ether of Bisphenol A (DGEBA) (commercial grade) (I) was supplied by Dr. Beck and Company (India) Ltd., Pune, and was used as received. The diglycidyl ether of 4,4'-dihydroxybenzylideneacetophenone (III) was synthesized as reported earlier [1].

The diglycidyl ether of 4,4'-dihydroxydibenzalacetone (II), the diglycidyl ether of 2,5-bis(4-hydroxybenzylidene)cyclopentanone (IV), the diglycidyl ether of 2,5-bis(4-hydroxy-3-methoxybenzylidene)cyclopentanone (V), and the diglycidyl ether of 2,6-bis(4-hydroxybenzylidene)- cyclohexanone (VI) were synthesized after Lee and Neville [5] with some modification of the method. In a 1-L three-necked round-bottom flask immersed in a Gallenkamp thermostatic oil bath and fitted with a mercurysealed stirrer, a reflux condenser, and a dropping funnel, 0.05 mol unsaturated ketone, 0.5 mol epichlorohydrin, and 540 mL 2-methoxy ethanol were mixed and heated to 100°C to completely dissolve the solid ketone with stirring. The temperature was raised to  $120 \pm 1^{\circ}$ C, and a 10% solution of sodium hydroxide in 2-methoxyethanol (0.1 mol) was added dropwise to the flask over a period of 3.5 h. After the addition was over, heating and stirring were continued for another hour. Unreacted epichlorohydrin, 2methoxyethanol, and accumulated water were distilled off. Resins II, V, and VI were extracted with toluene, dried over anhydrous magnesium sulfate, and solvent was distilled out under vacuum to obtain pure products (yield: II, 86%; V, 84%; VI, 86%).

Resin IV was washed several times with hot water to free it from sodium chloride and dried in a vacuum oven for 5 h (yield, 86%).

#### Synthesis of Divinyl Esters

In a 250-mL three-necked round-bottom flask fitted with a mercurysealed stirrer and a reflux condenser, and provided with thermostatic heating arrangements, the diglycidyl ethers, I-VI (0.1 mol), were reacted with acrylic acid (specific gravity 1.048, freezing point 13°C) (0.2 mol), in presence of benzyltrimethylammonium methoxide as catalyst (1 wt% of the total reaction mixture). Trace quantities (2-3 crystals) of hydroquinone were added to inhibit crosslinking during synthesis. The formation of the vinyl esters was followed by withdrawing samples of the reaction mixtures and recording the IR spectra at intervals of 30 min till the epoxy absorption at 915 cm<sup>-1</sup> vanished completely. Thus, the temperature and the total reaction time for the formation of vinyl esters VII-XII were optimized as given in Table 1.

Vinyl ester	Temperature, °C	Total reaction time, h
VII	120	2
VIII	90	4
IX	110	4.5
Х	140	2
XI	120	2
XII	140	1

TABLE 1

The reaction temperature was raised above  $90^{\circ}$ C in different cases to obtain a good reaction rate. The products were cooled and washed with methanol to free them from unreacted acrylic acid and dried. The resins were freely soluble in acetone, indicating the absence of any crosslinked product. *N,N*-Dimethylaniline can be used as a catalyst as reported earlier [1] for the synthesis of some of the resins, but it is not as versatile as benzyltrimethylammonium methoxide.

#### Spectral and Molecular Weight Measurements

The IR measurements were carried out on the solid and highly viscous samples in the form of KBr pellets and smears on the sodium chloride window, respectively, in a Perkin-Elmer double-beam 1330 IR spectrophotometer. The ultraviolet spectra were recorded for all samples by forming a thin coating on the outer transparent wall of a quartz cell, with a similar empty cell as the reference, in a Hitachi double-beam U-3200 spectrophotometer. The coatings were obtained from a 2% solution of the resins in either chloroform or acetone, whichever dissolved the resins better. The mass spectral measurements were carried out in a Finnigan Mat 1020 mass spectrometer operating at 70 eV.

The number-average molecular weights were measured in a Knauer vapor-pressure osmometer with universal probes in chloroform, dioxane, and tetrahydrofuran as solvent.

#### **UV** Irradiation

The quartz cells of the UV spectrometer, coated with resins as described above, were irradiated with intense UV light from a Hanovia highpressure mercury arc lamp provided with a vertical quartz jacket to circulate water at room temperature. The samples were kept at the distance of 15 cm from the walls of the jacket with the coated surface vertically facing the lamp. The photocrosslinking of the resins was followed by the gradual disappearence of the *trans*-CH=CH-CO- absorption in the resin and also by testing their insolubility in chloroform or acetone.

#### Chemical Curing

The vinyl esters were chemically cured by adding commercially available inhibited styrene as hardener (33.3 mL/100 g resin), methyl ethyl ketone peroxide (MEKP) as catalyst used for curing unsaturated polyesters (3 mL/100 g resin), and cobalt naphthenate as accelerator (3 mL/100 g resin) for 30 min at 98°C or 4 h at 50°C. At room temperature the curing was not appreciable for all the resins exposed to atmospheric oxygen. In addition, it is well known that MEKP with high dimer content is more reactive with vinyl polyesters than the low-dimer MEKP used by us in curing the vinyl esters [6].

#### **RESULTS AND DISCUSSION**

The diglycidyl ethers, I-VI (Scheme 1), and their vinyl esters, VII-XII (Scheme 2), were characterized by measurement of number-average molecular weight, mass spectral analysis for the M<sup>+</sup> ion, IR absorption of >C=O, >C=C<, and >C-O-C< groups (Tables 2 and 3). The glycidyl ethers were further characterized by the epoxide absorption around 915 cm<sup>-1</sup>. On the other hand, the vinyl esters were characterized by the disappearance of the absorption at 915 cm<sup>-1</sup> and the appearance of the ester peak at 1720 cm<sup>-1</sup>. In addition, the end vinyl group bending absorption consistently appeared at 985-980 cm<sup>-1</sup> (Table 3) [7]. The -OH absorption for the vinyl esters in the IR region was broad and could not be used to make any conclusive inference.

The maximum absorptions in the UV region observed at 340-365 nm for the glycidyl ethers (Table 2), which shifted to 340-395 nm for the vinyl esters (Table 3), were assigned to the -CH=CH-CO- group.

The  $\bar{m}_n$  measured by vapor pressure osmometry differed from the values of m/e for the M<sup>+</sup> ion of different resins (Tables 2 and 3), thereby indicating that the resins were not single compounds. The mass spectral peaks of measurable abundance beyond the M<sup>+</sup> ion shown in Tables 2 and 3 were observed but were not reported.

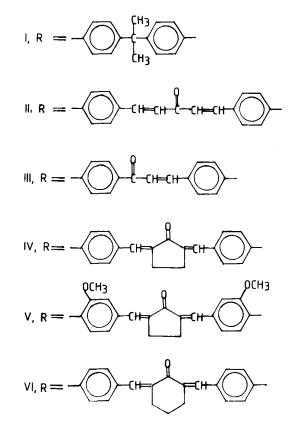
The solubility of the glycidyl ethers and the vinyl esters in several solvents was tested. All the resins were freely soluble in acetone, tetrahydrofuran, and dimethylformamide. Dioxane was also a good solvent at room temperature for most of the resins.

#### PHOTOREACTIONS

The photocrosslinking of the  $\alpha,\beta$ -unsaturated ketones by (2+2) cycloaddition of the unsaturated bond is a very well-known phenomenon [8-11] (Scheme 3).

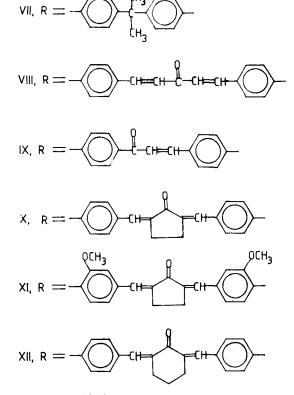
H<sub>2</sub> С-СH-СH<sub>2</sub>O-R-O-CH<sub>2</sub> CH-CH<sub>2</sub>

General formula of diglycidyl ethers



SCHEME 1. General formula of diglycidyl ethers.

#### PHOTOCROSSLINKABLE VINYL ESTERS

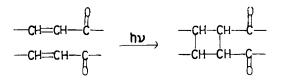


General formula of vinyl esters

ÇН<sub>3</sub>

SCHEME 2. General formula of vinyl esters.

СН<del>\_</del>СН-С-О-СН<sub>2</sub>-СН-СН<u>-</u>О-R-О-СН<sub>2</sub>-СН-СН<sub>2</sub>-С-С-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СН<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП<sub>2</sub>-СП



SCHEME 3. The photocrosslinking of the  $\alpha,\beta$ -unsaturated ketones by (2+2) cycloaddition of the unsaturated bond.

In several cases the crosslinking is accompanied by *tran-cis* isomerization although it can be suppressed by putting steric barriers in the structure of the compounds, particularly when they are oligomeric or polymeric, rendering the *cis* structure labile [12–14]. In the present study, all the diglycidyl ethers (except I) contained  $\alpha,\beta$ -unsaturated ketonic groups in their backbone, with the resin structure building up symmetrically from both ends. Such compounds are expected to undergo crosslinking and *cistrans* isomerization, the latter occurring simultaneously to a lower degree. This has been observed in the crosslinking behavior of the glycidyl ethers, II-VI, as reproduced in Figs. 1 to 3 for Resins II, III, and VI.

The vinyl esters VII-XII contained two vinyl end groups in addition to the  $\alpha,\beta$ -unsaturated ketonic moiety in their backbones (Scheme 2). We reported earlier [13, 14] that photo reactions of resins containing the -CH=CH-CO- group are symmetry sensitive and that its loss inhibited photocrosslinking. In the vinyl esters VII-XII, symmetric juxtaposition of the vinyl end groups with the -CH=CH-CO- group in the backbone is expected to increase the photocrosslinkability compared to that of the parent diglycidyl ethers. This expectation has been borne out by our experiments (e.g., Figs. 4-6). The vinyl ester of DGEBA, VII, having only the vinyl groups at the ends without a -CH=CH-CO- group in the backbone, did not crosslink appreciably even after 15 h of irradiation.

To obtain a quantitative picture of the relative photofastness of the glycidyl ethers and their vinyl esters, the conversion of the -CH=CH-CO- group with the (2+2) cyclic structure leading to crosslinking was plotted against the time of irradiation in Figs. 7-11. The percentage conversion of the -CH=CH-CO- group was taken to be  $[(A_t - A_0)/(A_\infty - A_0)] \times 100$ , where  $A_0$  is the absorbance at time zero,  $A_t$  is the absorbance at time t, and  $A_\infty$  is the absorbance at the completion of the reaction. It is seen from Figs. 7-11 that all the vinyl ethers photocrosslinked much faster than their parent diglycidyl ethers, indicating synergy,

TABLE 2. Spectral Characteristics of Diglycidyl Ethers<sup>a</sup>

	Name of	Molecular		λ <sub>max</sub> (trans- -CH=CH-CO-),	V>C=0,	V>C=C<	V <sub>L</sub> O <sub>L</sub> CH <sub>2</sub> ,	V>C_0-C€;
No.	No. the compound	weight	<i>m/e</i> , M <sup>+</sup>	nm	cm <sup>-1</sup>	cm <sup>-1</sup>	cm <sup>-1</sup>	cm <sup>-1</sup>
I	Diglycidyl ether of Bispherol A	359	361 (100%) 376 (22.8%) 397 (43.8%),				915(s)	1245(s)
п	Diglycidyl ether of bis(4-	364	412 (o.1%) 378 (100%)	360	1640(s)	1620(sh)	915(s)	1250(s)
Ш	Diglycidyl ether of 4,4'-di- hydroxybenzylidene-	380	352 (100%)	340	1650(s)	1630(sh)	915(s)	1250(s)
N	Diglycidyl ether of 2,5-bis(4-4( hydroxybenzylidene)cyclo-	400	404 (65.4%)	342	1680(s)	1620(w)	925(w)	1250(s)
>	pentatione Diglycidyl ether of 2,5-bis(4- hydroxy-3-methoxybenzyl- idana)wodoroantanoora	504	464 (50.4%)	365	1670(m)	1615(s)	915(w)	1240(s)
IA	Diglycidyl ether of 2,6-bis(4- hydroxybenzylidene)cyclo- hexanone	433	418 (26%)	345	1655(s)	1625(w,sh)	915(s)	1250(s)

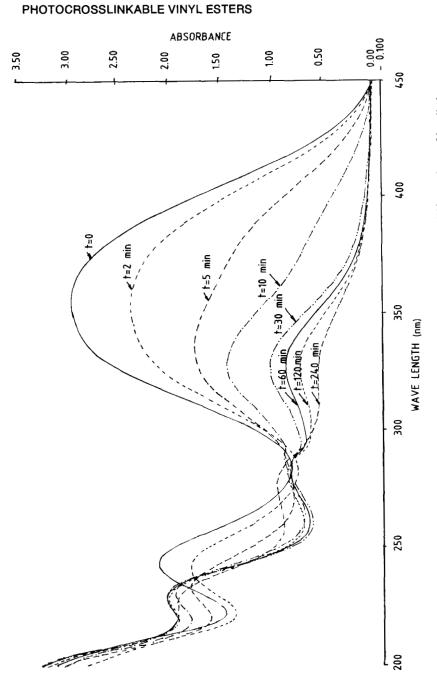
<sup>a</sup>s = strong, m = medium, w = weak, sh = shoulder.

Downloaded At: 17:48 24 January 2011

TABLE 3. Spectral Characteristics of Vinyl Esters<sup>a</sup>

, No	Name of the compound	Molecular weight	<i>m/e</i> , M <sup>+</sup>	λ <sub>max</sub> (trans- -CH=CH-CO-), nm	v-co-o-, v>c=o, cm <sup>-1</sup> cm <sup>-1</sup>	v>c=0. cm <sup>-1</sup>	v>c=c<, cm <sup>-1</sup>	$v_{SC=C<}$ $v_{SC-O-C}$ , $v_{C-O-C}$ $cH_{2'}$ $cm^{-1}$	δ-CH=CH <sub>2</sub> , cm <sup>-1</sup>
IIA	Divinyl ester of diglycidyl ether of Bisphenol A	524	505 (13%) 520 (4.2%) 541 (3.3%) 556 (1.6%)	287 278	1720(s)			1245(s)	985(m)
IIIV	Divinyl ester of diglycidyl ether of bis(4-hydroxy- henzvlidene)acefone	502	522 (4.4%)	380	1720(s)	1635(m) 1620(w)	1620(w)	1255(s)	985(s)
XI	Divinyl ester of diglycidyl ether of 4,4'-dihydroxy-	551	496 (3%)	340	1720(s)	1650(m)	1650(m) 1620(sh)	1255(s)	980(m)
×	Divinyl ester of diglycidyl ether of 2,5-bis(4-hydroxy- benzylidene)cyclo-	584	548 (5.3%)	375	1720(s)	1680(sh)	1680(sh) 1620(w)	1250(s)	985(s)
X	penanoue Divinyl ester of diglycidyl ether of 2,5-bis(4-hydroxy- 3-methoxybenzylidene)- cyclonertranoue	556	608 (29.1%)	395	1720(s)	1680(sh)	1680(sh) 1620(w)	1250(s)	980(s)
IIX	Divinyl ester of diglycidyl ether of 2,6-bis(4-hydroxy- benzylidene)cyclohexanone	554	562 (43.3%)	365	1720(s)	1650(w)	1630(w)	1250(s)	980(s)

 $a_s = strong, m = medium, w = weak, sh = shoulder.$ 





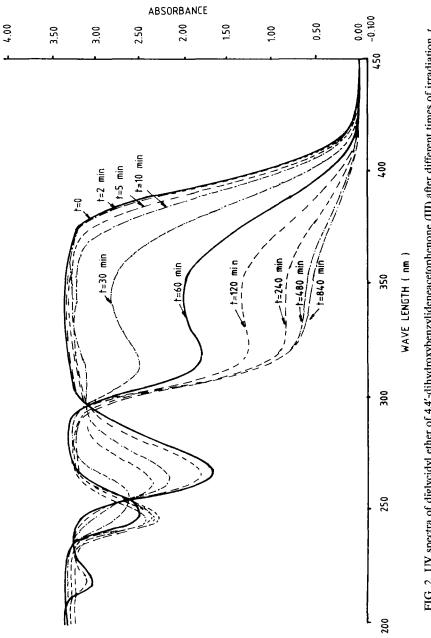
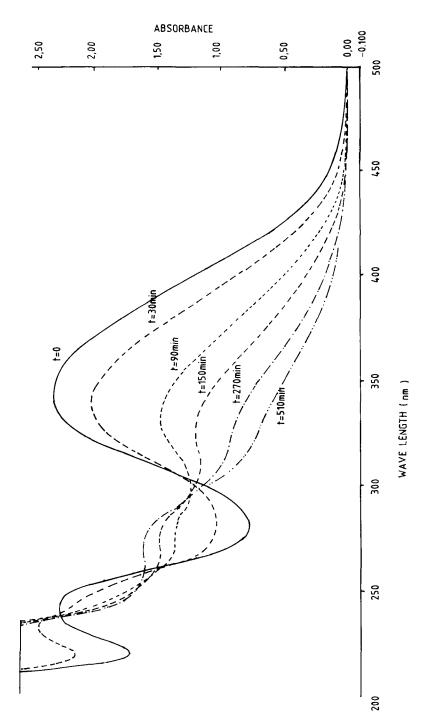


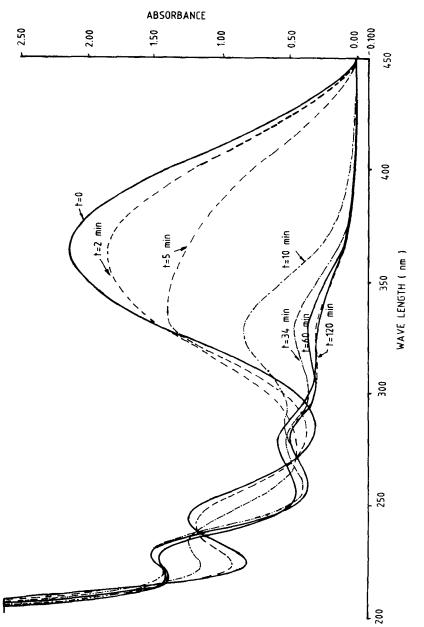
FIG. 2. UV spectra of diglycidyl ether of 4,4'-dihydroxybenzylideneacetophenone (III) after different times of irradiation, t.

Downloaded At: 17:48 24 January 2011

12

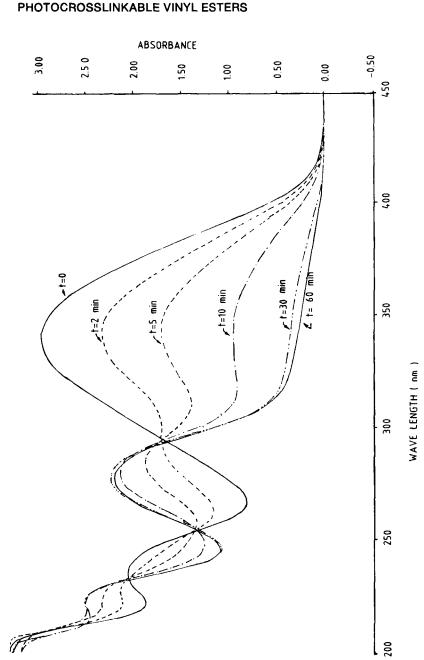




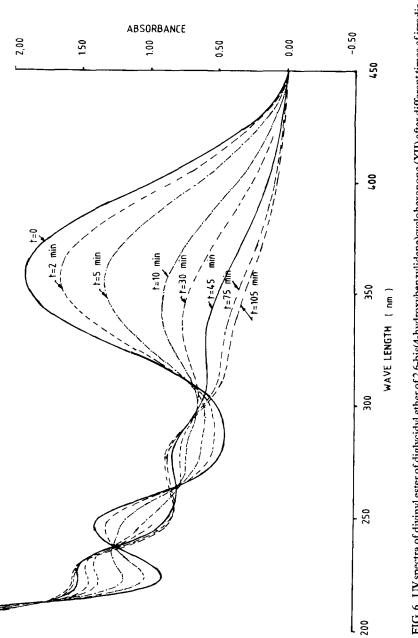


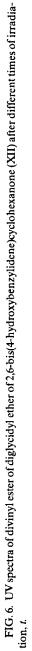


14









16

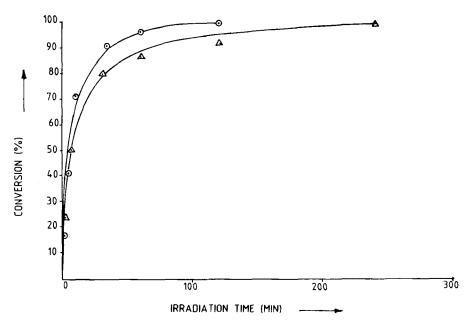
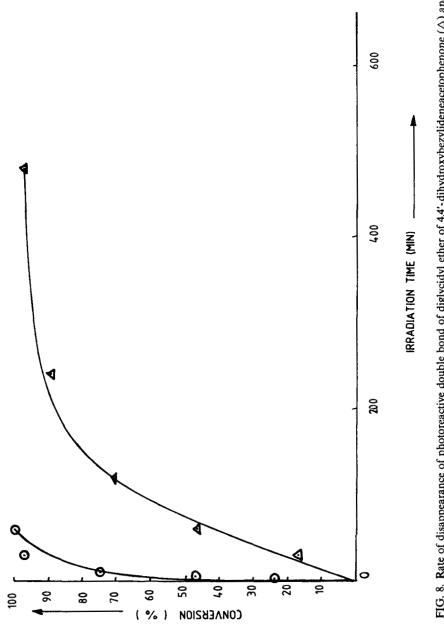


FIG. 7. Rate of disappearance of photoreactive double bond of diglycidyl ether of bis(4-hydroxybenzylidene) acetone ( $\triangle$ ) and its divinyl ester ( $\odot$ ).

the fastest being Resin IX which reached 100% conversion within 60 min of irradiation. The order of their ease of photocrosslinkability is IX > XII > VIII > X > XI.

The relative photofastness of the vinyl esters may be of some research curiosity but loses most of its significance in thick films, 1 mm or above, in different applications. We found that the resins could not be cured even after 2-3 h of irradiation in thick films.

In addition to crosslinking with UV light, the vinyl esters were also tested for their chemical curability by the addition of styrene as hardener, MEKP as catalyst, and cobalt naphthenate as accelerator, as described earlier. All the resins crosslinked completely within 30 min at 98°C, with the exception of VII, which did not crosslink at all under similar conditions. The chemical crosslinking is expected to proceed via free-radical polymerization of the unsaturated end groups of the vinyl esters because the -CH=CH-CO- does not copolymerize with styrene. It appears that in vinyl esters with  $\alpha,\beta$ -unsaturated ketone groups in the backbone and





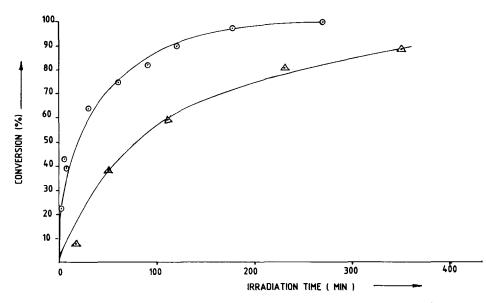


FIG. 9. Rate of disappearance of photoreactive double bond of diglycidyl ether of 2,5bis(4-hydroxybenzylidene)cyclopentanone ( $\Delta$ ) and its divinyl ester ( $\odot$ ).

vinyl end groups symmetrically placed, there is some synergy in chemical curing as well. This can be exploited by curing vinyl esters for several applications by UV irradiation to decrease the exothermicity of curing, followed by chemical crosslinking of the residual vinyl end groups obtained by heating with the hardener system that was added to the resins at the outset.

Vinyl esters without  $\alpha$ , $\beta$ -unsaturated ketone groups in their backbones are reported to crosslink very fast under UV irradiation with the addition of triplet-state sensitizers like benzophenone or benzoin ethers [15]. Our work carried out along similar lines will be reported shortly.

#### ACKNOWLEDGMENTS

The authors are thankful to the Director, Directorate of Training and Sponsored Research, Research and Development Organization, Ministry of Defence, New Delhi, for alloting a Junior Research Fellowship to Miss Meher S. Mirza and alloting a Defence Grants-in-Aid Project to Dr. S. P.

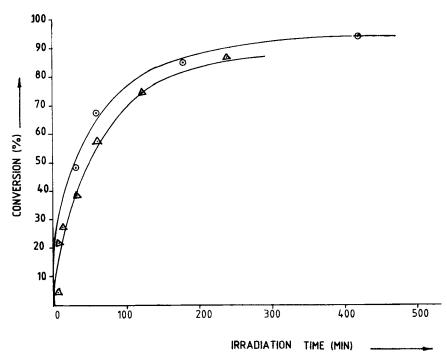


FIG. 10. Rate of disappearance of photoreactive double bond of diglycidyl ether of 2,5bis(4-hydroxy-3-methoxybenzylidene)cyclopentanone ( $\triangle$ ) and its divinyl ester ( $\bigcirc$ ).

Panda, under which the present work was carried out. Dr. E. Bhagiratharao, Director and Dean, I.A.T., is warmly thanked for his kind interest and permission to publish this paper.

#### REFERENCES

- D. S. Sadafule, R. N. Raghuraman, N. G. Navale, C. G. Kumbhar, and S. P. Panda, J. Macromol. Sci.-Chem., A25(1), 121-126 (1988).
- F. P. Gerstle Jr., in *Encyclopedia of Polymer Science and Engineering*, Vol. 3 (H. F. Mark, N. M. Bikales, C. G. Overberger, G. Menges, and J. I. Kroschwitz, eds.), Wiley, New York, 1985, p. 796.
- [3] A. Z. Sheik, J. Appl. Polym. Sci., 23, 1355 (1979).
- [4] D. G. Borden, *Ibid.*, 22, 239-251 (1978).

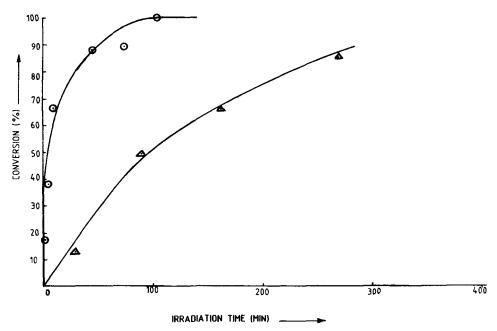


FIG. 11. Rate of disappearance of photoreactive double bond of diglycidyl ether of 2,6bis(4-hydroxybenzylidene)cyclohexanone ( $\triangle$ ) and its divinyl ester ( $\bigcirc$ ).

- [5] H. Lee and K. Neville, Handbook of Epoxy Resins, McGraw-Hill, London, 1967, pp. 4–17.
- [6] T. F. Anderson and V. B. Messick, in *Developments in Reinforced Plastics. I. Resin Matrix Aspects* (G. Prichard, ed.), Applied Science Publishers, London, 1980, p. 39.
- [7] L. J. Bellamy, The Infrared Spectra of Complex Molecules, Vol. 2, 2nd ed., Chapman and Hall, London, 1980, p. 44.
- [8] S. P. Panda. J. Sci. Ind. Res., 35, 560-570 (1976).
- [9] J. G. Calvert and J. N. Pitts, *Photochemistry*, Wiley, New York, 1969, p. 538.
- [10] A. Schonberg, Perparative Organic Photochemistry, Springer-Verlag, Berlin, 1968, pp. 75-90.
- [11] S. Tazuke, in *Developments in Polymer Photochemistry*, Vol. 3 (N. S. Allen, ed.), Applied Science Publishers, London, 1982, pp. 84-91.

- [12] S. P. Panda, J. Appl. Polym. Sci., 18, 2317 (1974).
- [13] D. S. Sadafule and S. P. Panda, Ibid., 24, 511-521 (1979).
- [14] D. S. Sadafule and S. P. Panda, Polym. Photochem., 2, 13-21 (1982).
- [15] T. F. Anderson and V. B. Messick, in *Developments in Reinforced Plas*tics. I. Resin Matrix Aspects (G. Pritchard, ed.), Applied Science Publishers, London, 1980, p. 35.

Received August 19, 1988 Revision received December 14, 1988